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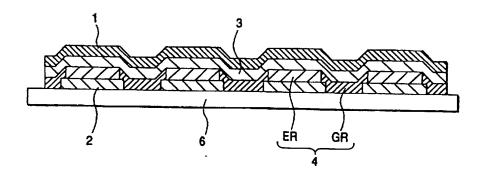
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(54) Organic electroluminescent display panel with reduced pixel cross-talk

(57) An organic electroluminescent (EL) display panel consists of a layer of anode stripes 2, formed on a substrate 6 which is covered with a high polymer layer 4 which acts as a hole injection layer for an overlaying organic light-emitting layer 3. A layer of cathode stripes 1 on top of the light-emitting layer 3 is arranged orthogonally to the anode stripes 2. The anodes are preferably ITO or Au and the cathodes are preferably A1 or In or Ag alloys. The crossed pattern of electrode stripes forms an array of pixels at each point of overlap. The high polymer layer 4, preferably conducting camphor-sulphonic acid (CSA) doped polyaniline material, has a varying conductivity such that in regions GR between the anode stripes, the conductivity is relatively low, possibly insulating compared to regions ER over the anode stipes. A method of forming a pattern of varying conductivity in the polyaniline involves masking portions with a standard photoresist technique and either i). applying an alkaline ammonium solution to reduce regions of a high CSA doped polyaniline layer and thus reduce the conductivity or ii). applying a sulphuric acid solution to increase the doping level and thus the conductivity of a low doped polyaniline layer.

FIG. 1



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At least one drawing originally filed was informal and the print reproduced here is taken from a later filed formal copy.

FIG. 1

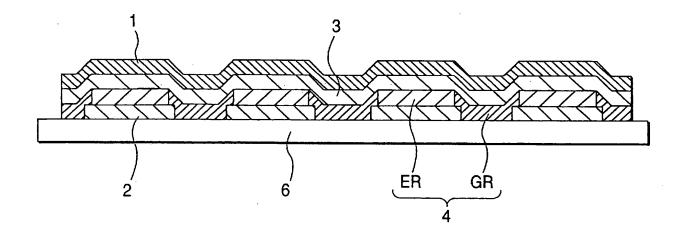
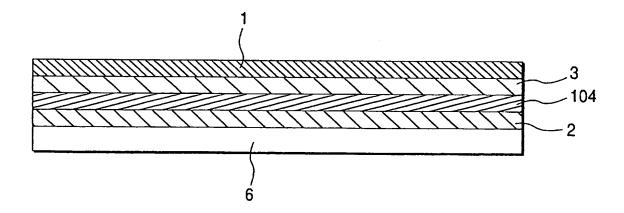
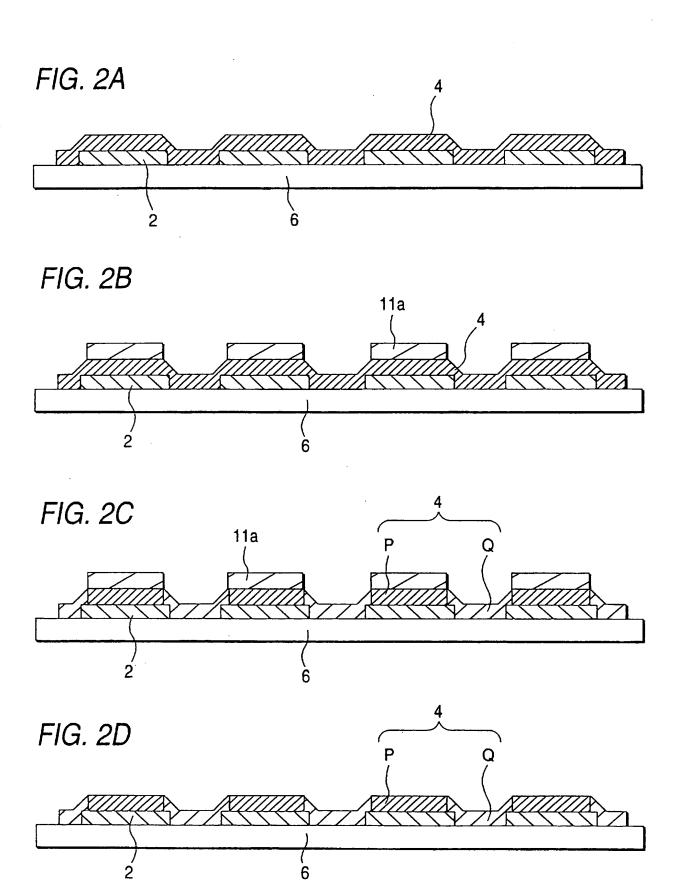
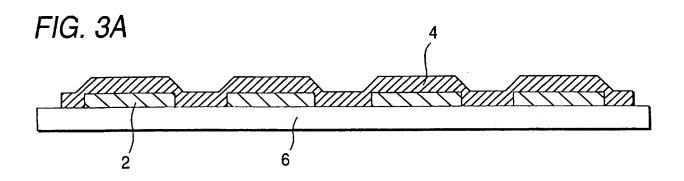


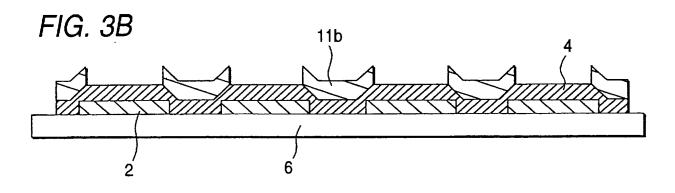
FIG. 4

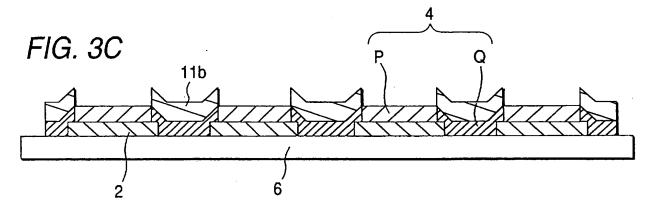


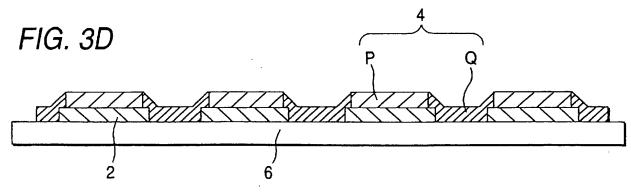
BNSDOCID: <GB_____2332985A__I_;











ORGANIC EL DISPLAY PANEL AND ITS MANUFACTURING METHOD

The present invention relates to an organic EL (Electroluminescence) display panel and its manufacturing method, and particularly to an organic EL display panel and its manufacturing method using a conductive high polymer layer between an anode layer and an organic EL layer.

A display panel has been known which uses an organic electroluminescence element (hereinafter referred to as "organic EL element) which passes a current through a fluorescent body formed on a glass plate or a transparent organic film to emit light. The organic EL element, as shown in Fig. 4, includes an organic layer 2 comprising a plurality of transparent electrodes of ITO, a conductive high polymer layer 104 for improving reliability, an organic EL layer 3 comprising a hole transporting layer and a light emitting layer, and a cathode layer 1 comprising a plurality of metallic electrodes intersecting the anode layer 2. These layers are successively stacked on a transparent substrate 6 of glass or the like. The anode layer 2 and cathode layer 1, between which the organic EL layer 3 intervenes and which are opposite to each other to form a couple, constitutes a light emitting portion serving as an organic EL layer 3. An

intersecting region where each of the transparent electrodes of the anode layer 2 and each of the metallic electrodes of the cathode layer 1 are opposite to intersect constitutes a pixel of one unit.

As the cathode 1, a metal having a small work function such as an alloy of Al, In, Ag, etc.(e.g. Al-Li alloy) is used. As the anode layer 2, a conductive material having a large work function of ITO (work function of ITO = about 0.5 eV) or gold (work function of Au = about 5.1 eV) is used. When gold is used as an electrode material, the electrode is made semi-transparent.

As the high polymer layer 104, polyaniline is used. Improvement of reliability in the conductive high polymer layer is disclosed in JP-A-9-45479. (The term "JP-A" as herein means "unexamined published Japanese patent application".)

When the technique for improving reliability by the conductive high polymer layer is adopted for a display panel having a structure where an anode and cathode are divided into plural regions, such as a dot matrix, because the resistance of the conductive high polymer layer is low, the adjacent anode regions are electrically connected to each other and hence crosstalk occurs. Namely, even when a current is not passed through the anode in order that the pixel on a certain anode does not emit light, the current flows from the adjacent anode because the electric resistance of the high polymer layer is low. Thus, the pixel which should not emit light will emit light. As a result, a desired image cannot be obtained.

An object of the present invention is to provide an organic EL display panel with improved reliability and a method of manufacturing it in such a manner that after a high polymer layer has been deposited on an anode layer, a desired region is made conductive or non-conductive to form the conductive high polymer layer thereon.

In order to solve the above problem, an organic EL display panel defined in a first aspect of the present invention comprises a plurality of anode layers laminated on a substrate and arranged with intervals in a direction perpendicular to the laminating direction (hereinafter sometimes simply referred to as a plurality of anode layers at intervals), a high polymer layer made of polymeric material, an organic EL layer and a plurality of cathode layers arranged with spaces (intervals) in a direction perpendicular to the laminating direction, these layers being successively stacked, and characterized in that gap regions corresponding to the intervals in the high polymer layer (gap regions disposed between the adjacent anode layers) are formed to have a lower conductivity than regions corresponding to the anode layers (energizing regions facing the cathode layers).

The organic EL display panel defined in a second aspect of the present invention is an organic EL display panel according to the first aspect of the present invention, wherein the gap regions of the high polymer layer are insulating (insulative).

The organic EL display panel defined in a third aspect of the present invention is an organic EL display panel comprising a plurality of anode layers formed to be arranged at predetermined intervals on a substrate, and a conductive high polymer layer, an organic EL layer and a cathode layer, these layers being successively stacked on the anode layers, wherein the conductive high polymer layer, after it has been stacked, is subjected to a conductivity reducing step of reducing the conductivity of gap regions corresponding to the intervals.

The organic EL display panel defined in a fourth aspect of the present invention is an organic EL display panel according to the third aspect of the present invention, wherein the gap regions of the conductive high polymer layer is made insulating by the conductivity reducing step.

The organic EL display panel defined in a fifth aspect of the present invention is an organic EL display panel according to the third or fourth aspect of the present invention, wherein the conductive high polymer is made of polyaniline mixed with camphor-sulfonic acid, and the conductivity reducing step is carried out in such a manner that the gap regions of the conductive high polymer layer is immersed in an alkaline solution.

The organic EL display panel defined in a sixth aspect of the present invention is an organic EL display panel comprising a plurality of anode layers formed to be arranged at intervals on a substrate, a non-conductive high polymer layer, which can

be imparted conductivity, formed thereon, and an organic EL layer and a cathode layer which are successively stacked on the non-conductive high polymer layer, wherein the non-conductive high polymer layer, after it has been stacked, is subjected to a conductivity imparting step of reducing the conductivity of energizing regions corresponding to the anode layers.

The organic EL display panel defined in a seventh aspect of the present invention is an organic EL display panel according to the sixth aspect of the present invention, wherein the non-conductive high polymer is made of polyaniline, and the conductivity imparting step is carried out in such a manner that the energizing regions are immersed in an acidic solution.

The method defined in a eighth aspect of the present invention is a method of manufacturing an organic EL display panel comprising the steps of: forming a plurality of a plurality of anode layers so as to be arranged at predetermined intervals on a substrate; stacking a conductive high polymer layer on the substrate so as to cover the plurality of anode layers; reducing the conductivity of gap regions corresponding to the intervals of the conductive high polymer layer; and successively stacking an organic EL layer and a cathode layer on the conductive high polymer layer.

The method defined in ninth aspect of the present invention is a method of manufacturing an organic EL display panel according to the eight aspect of the present invention, wherein

the step of reducing conductivity is to make the gap regions insulating.

The method defined in a tenth aspect of the present invention is a method of manufacturing an organic EL display panel according to the eighth or ninth aspect of the present invention, wherein the conductive high polymer layer is polyaniline mixed with camphor-sulfonic acid, and the conductivity reducing step is carried out in such a manner that the gap regions of the conductive high polymer layer is immersed in an alkaline solution.

The method defined in a eleventh aspect of the present invention is a method of manufacturing an organic EL display panel comprising the steps of: forming a plurality of anode layers so as to be arranged at intervals on a substrate, stacking a non-conductive high polymer layer, which can be imparted conductivity, on the substrate so as to cover the plurality of anode layers; imparting conductivity to energizing regions corresponding to the anode layers of the non-conductive high polymer layer; and successively stacking an organic EL layer and a cathode layer on the conductive high polymer layer.

The method defined in a twelfth aspect of the present invention is a method of manufacturing an organic EL display panel according to the eleventh aspect of the present invention, wherein the non-conductive high polymer is made of polyaniline, and the conductivity imparting step is carried out in such a manner that the energizing regions are immersed in an acidic solution.

In accordance with the present invention, since electric connection between adjacent anode layers can be avoided, in a matrix display having a high polymer layer, the crosstalk which was problematic can be minimized.

BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a partial sectional view showing an organic EL display panel according to the present invention.

Figs. 2A to 2D are views showing the manufacturing process according to the first embodiment of an organic EL display panel according to the present invention.

Figs. 3A to 3D are views showing the manufacturing process according to the second embodiment of an organic EL display panel according to the present invention.

Fig. 4 is a partial sectional view showing a conventional organic EL display panel.

In the drawings:-

Now referring to Fig. 1, an explanation will be given of the first embodiment of the present invention.

Fig. 1 is a partial sectional view of the structure of an organic EL display panel according to the present invention.

As shown in Fig. 1, an organic EL display panel includes a plurality of anode layers 2 of ITO, a high polymer layer 4, an organic EL layer 3 comprising a hole transporting layer and light

emitting layer, and cathode layers 1 comprising a plurality of metal electrodes intersecting the anode layers. The regions are successively stacked in the order described above on a transparent substrate 6 made of glass or the like. The plurality of anode layers 2, which are belt-shaped, respectively, are arranged in parallel to each other at predetermined intervals.

The plurality of cathode layers 1, which are belt-shaped like the anode layers 2, respectively, are arranged in parallel to each other at predetermined intervals. The cathode layers 1 and anode layers 2 are substantially orthogonal to each other in their extending direction. The regions where these layers intersect each other, i.e. the regions of the organic EL layer 3 sandwiched between the cathode layers 1 and anode layers 2 constitute light emitting regions and correspond to respective pixels.

The cathode layers 1 are made of a metal (e.g. Al - Li alloy) having a small work function such as an alloy of Al, In, or the like. The anode layers 2 are made of a conductive material having a large work function such as ITO, or made of gold (Au). The electrode made of Au is in a semi-transparent state.

The high polymer layer 4 is formed so that its regions (energizing regions: ER) which face the anode layers 2 are made conductive, and its regions (gap regions: GR) corresponding to the intervals between the adjacent anode layers 2 are not conductive.

In this configuration, without increasing the resistance between the cathode layers 1 and anode layers 2 in the light emitting regions, the adjacent anode layers can be electrically isolated so that the crosstalk can be avoided without deteriorating the light emitting characteristic of the display.

As seen from the figure, the gap region of the high polymer layer 4 is caused to extend over the edge of each of the anode layers 2 so that the leak-out of a current from the edge can be restrained.

An explanation will be given of a process for manufacturing a high polymer layer 4 according to the present invention.

Embodiment 1

The first embodiment adopts a step of forming a conductive high polymer layer once, and reducing the conductivity of the areas of the high polymer layer thus formed, corresponding to the gaps of the anode layers 2. As shown in Fig. 2A, a transparent substrate 6 such as glass with ITO constituting the anode layers 2 patterned in stripes is sufficiently cleaned. Thereafter, a conductive high polymer layer 4 is formed on the substrate 6 inclusive of the anode layers 2 thus patterned. In this case, the conductive high polymer layer 4 is formed in such a manner that a polyaniline (PAn) solution mixed with camphor-sulfonic acid (CSA) is laminated by spin coating, and dried by a clean oven to deposit a CSA-doped PAn layer having a thickness of 500 A.

A photoresist 11a (OFPR-800LB) available from TOKYO OUKA is laminated by spin coating, and photoresist patterns are formed at pixel portions though a predetermined step (Fig. 2B). The substrate thus formed is immersed in an ammonium solution to eliminate the doping of the CSA-doped PAn layer at the areas other than the pixels (Fig. 2C).

Finally, the photoresist 11a is eliminated to complete the high polymer layer 4 (Fig. 2D). Thereafter, the organic EL layer inclusive of an emitting layer and a cathode layer are successively stacked.

Since the doping is eliminated, of the conductive high polymer layer 4, the areas Q corresponding to the intervals between the anodes have lower conductivity than that of the areas P corresponding to the anodes.

Finally, sealing is performed to complete an organic EL display panel. As a result of a display action using a prototype of the organic EL display panel having 256 x 64 dots, a light emitting state with no crosstalk has been obtained.

Embodiment 2

The second embodiment adopts a step of forming a non-conductive high polymer layer once, and imparting conductivity to the regions of the high polymer layer thus formed, facing the anode layers 2. As shown in Fig. 3A, a transparent substrate 6 such as glass with ITO constituting the anode layers 2 patterned in stripes is sufficiently cleaned. Thereafter, a non-

conductive high polymer layer 4 is formed on the substrate 6 inclusive of the anode layers 2 thus patterned. In this case, the non-conductive high polymer 4 is formed in such a manner that a polyaniline (PAn) is laminated by spin coating, and dried by a clean oven to deposit a PAn layer having a thickness of 500 A.

A photoresist 11b (OFPR-800LB) available from TOKYO OUKA is laminated by spin coating, and photoresist patterns are formed at the gap regions between adjacent anodes though a predetermined step (Fig. 3B). The substrate thus formed is immersed in a sulfuric acidic solution to effect the doping of the PAn layer at the areas corresponding to the pixels (Fig. 3C).

Finally, the photoresist 11a is eliminated to complete the high polymer layer 4 (Fig. 3D). Thereafter, the organic EL layer inclusive of an emitting layer and a cathode layer are successively stacked.

Since the doping is effected, in the non-conductive high polymer layer 4, the areas P corresponding to the anodes are made conductive while the areas Q corresponding to the gaps between the anodes remain non-conductive.

Finally, sealing is performed to complete an organic EL display panel. As a result of a display action using a prototype of the organic EL display panel having 256 x 64 dots, a light emitting state with no crosstalk has been obtained.

Incidentally, the regions (gap regions) of the high polymer layer 4, which have been made non-conductive, are most

preferably insulating. However, as long as they have lower conductivity than the regions (energizing regions: ER), which have been made conductive, occurrence of crosstalk can be restrained as compared to the prior art.

The regions (energizing regions: ER) of the high polymer layer 4, which have been made conductive, may be caused to correspond to the light emitting regions where the cathode layers 1 and the anode layers 2 intersect each other while the other remaining regions may be made non-conductive.

Effects of the Invention:

As described above, in accordance with the present invention, since electric connection (energizing) between adjacent anode layers can be avoided to the utmost, the crosstalk which was problematic can be minimized so that an more improved image can be obtained than before.

CLAIMS

- 1. An organic EL display panel comprising:
- a substrate;

a plurality of anode layers laminated on said substrate in a laminating direction and arranged with intervals in a direction perpendicular to the laminating direction;

a high polymer layer laminated on said anode layers; an organic EL layer laminated on said high polymer layer; and

a plurality of cathode layers laminated on said organic EL layer in a laminating direction and arranged with spaces in a direction perpendicular to the laminating direction,

wherein said high polymer layer comprises: an energizing region facing said cathode layers; and a gap region disposed between said adjacent anode layers,

wherein said gap region has a conductivity lower than said energizing region.

- 2. An organic EL display panel according to claim 1, wherein said gap region of said high polymer layer is insulative.
- 3. An organic EL display panel formed by laminating on a substrate, a plurality of anode layers arranged with intervals in a direction perpendicular to the laminating direction, a conductive high polymer layer, an organic EL layer, and a plurality

of cathode layers arranged with spaces in a direction perpendicular to the laminating direction, in this order,

wherein said conductive high polymer layer comprises: an energizing region facing the cathode layers; and a gap region disposed between said adjacent anode layers,

wherein said conductive high polymer layer is subjected to a conductivity reducing step of reducing the conductivity of said gap region, after said conductivity high polymer has been laminated on said anode layers.

- 4. An organic EL display panel according to claim 3, wherein said gap region of said conductive high polymer layer is made insulative by said conductivity reducing step.
- 5. An organic EL display panel according to claim 3 or 4, wherein said conductive high polymer comprises polyaniline mixed with camphor-sulfonic acid, and said conductivity reducing step is carried out in such a manner that said gap region of said conductive high polymer layer is immersed in an alkaline solution.
- 6. An organic EL display panel formed by laminating on a substrate, a plurality of anode layers arranged with intervals in a direction perpendicular to the laminating direction, a non-conductive high polymer layer capable of being imparted conductivity, an organic EL layer, and a plurality of cathode

layers arranged with spaces in a direction perpendicular to the laminating direction, in this order,

wherein said non-conductive high polymer layer comprises: an energizing region facing said cathode layers; and a gap region disposed between said adjacent anode layers,

wherein said non-conductive high polymer layer is subjected to a conductivity imparting step of reducing the conductivity of the energizing region, after said non-conductivite high polymer layer has been laminated on said anode layers.

- 7. An organic EL display panel according to claim 6, wherein said non-conductive high polymer layer comprises polyaniline, and said conductivity imparting step is carried out in such a manner that said energizing region is immersed in an acidic solution.
- 8. A method of manufacturing an organic EL display panel comprising the steps of:

forming a plurality of anode layers so as to be arranged with intervals on a substrate;

laminating a conductive high polymer layer on said substrate so as to cover said plurality of anode layers, wherein said conducting high polymer layer comprises a gap region disposed between said adjacent anode layers;

reducing the conductivity of the gap region;; and successively laminating an organic EL layer and a cathode layer on said conductive high polymer layer.

- 9. A method of manufacturing an organic EL display panel according to claim 8, wherein the step of reducing conductivity is to make said gap region insulative.
- 10. A method of manufacturing an organic EL display panel according to claim 8 or 9, wherein said conductive high polymer layer is polyaniline mixed with camphor-sulfonic acid, and said conductivity reducing step is carried out in such a manner that said gap region of said conductive high polymer layer is immersed in an alkaline solution.
- 11. A method of manufacturing an organic EL display panel comprising the steps of:

forming a plurality of anode layers so as to be arranged with intervals on a substrate;

laminating a non-conductive high polymer layer capable of being imparted conductivity on said substrate so as to cover said plurality of anode layers, wherein said non-conducting high polymer layer comprises an energizing region facing a plurality of cathode layers;

imparting conductivity to the energizing region of said

non-conductive high polymer layer; and

successively laminating an organic EL layer and the cathode layers on said non-conductive high polymer layer.

- 12. An organic EL display panel according to claim 11, wherein said non-conductive high polymer comprises polyaniline, and said conductivity imparting step is carried out in such a manner that said energizing region are immersed in an acidic solution.
- 13. A method substantially as described with reference to figures 1 to 3D of the accompanying drawings.
- 14. A display panel substantially as described with reference to figures 1 to 3D of the accompanying drawings.







Application No:

GB 9828870.7

Claims searched: 1 at least

Examiner:

Gareth Lewis

Date of search:

14 April 1999

Patents Act 1977
Search Report under Section 17

Databases searched:

UK Patent Office collections, including GB, EP, WO & US patent specifications, in:

UK Cl (Ed.Q): H1K KEAL, KEAX

Int Cl (Ed.6): H01L 51/20 51/30 H05B 33/26 33/28

Other: Online: WPI, IFIPAT, JAPIO, INSPEC

Documents considered to be relevant:

Category	Identity of document and relevant passage		Relevant to claims
Y.	WO 97/23452 A1	Zhang (See esp. page 4 line 11 to page 5 line 36 and page 25 lines 8-36)	5,10
X, Y	WO 96/08047 A2	Staring (Whole doc esp. figures 1,2, page 3 lines 11-28 and page 5 lines 24-33)	X: 1-4,8,9 Y: 5,10
A,P	US 5719467 A	Antoniadis (Whole Document)	
A	US 5626795 A	Smith (Whole document)	

X Document indicating lack of novelty or inventive step

Document indicating lack of inventive step if combined with one or more other documents of same category.

[&]amp; Member of the same patent family

A Document indicating technological background and/or state of the art.

P Document published on or after the declared priority date but before the filing date of this invention.

E Patent document published on or after, but with priority date earlier than, the filing date of this application.